

ETSC – Embedded & Wirebond Temperature Silicon Capacitor

Rev 3.6



Key features

- High Operating temperature (200°C)
- Low profile (250µm)
- High stability of capacitance value:
 - **◆** Temperature ±1% (-55°C to +200°C)
 - Voltage <0.1%/Volts
 - Negligible capacitance loss through ageing
- Low leakage current down to 100pA
- High reliability
- Pad finishing : Aluminum

Thanks to the unique IPDiA Silicon capacitor technology, most of the problems encountered in demanding applications can be solved.

Embedded Temperature Silicon Capacitors are dedicated to applications where **reliability** up to **200°C** is the main parameter.

ETSC are the most appropriate solution for Chip On Board, Chip On Foil, Chip On Glass, Chip On Ceramic, flip chip and embedded applications.

This technology features a capacitor integration capability (up to 250nF/mm²) which offers capacitance value similar to X7R dielectric, but with better electrical performances than C0G/NP0 dielectrics, up to 200°C.

Key applications

- All applications up to 200°C, such as defense, downhole and automotive industries
- High reliability applications
- Replacement of X7R and C0G dielectrics
- Decoupling / Filtering / Charge pump (i.e.: motor management, temperature sensors)
- Downsizing

ETSC provides the highest capacitor **stability** over the full -55°C/+200°C temperature range in the market with a **TC<1%**.

The IPDiA technology offers industry leading performances relative to **Failure rate** with a FIT<0.017.

This technology also offers **high reliability**, up to 10 times better than alternative capacitor technologies, such as Tantalum or MLCC, and eliminates cracking phenomena.

This Silicon based technology is ROHS compliant and compatible with lead free reflow soldering process.



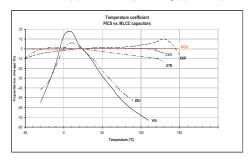


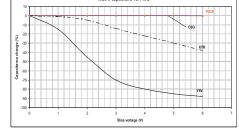
Electrical specification

			Capacitance value						
		10	15	22	33	39	47	68	
	10pF	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	390pF/0202/30V 935 124 72C 339	470pF/0202/30V 935 124 72C 347	680pF/0202/30V 935 124 72C 368	
	0.1nF	1nF/0202/30V 935 124 72C 410	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	
Unit	1nF	10nF/0202/30V 935 124 72C 510	Contact IPDIA Sales	Contact IPDIA Sales	33nF/0404/30V 935 124 72F 533	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	
	10nF	100nF/0404/11V 935 124 42F 610 100nF/0605/30V 935 124 72G 610	Contact IPDIA Sales	220nF/0505/11V 935 124 42H 622	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	Contact IPDIA Sales	
	0.1µF	1μF/1208/11V 935 124 42S 710 1μF/1616/30V 935 124 72Y 710	Contact IPDIA Sales	2.2µF/1612/11V 935 124 42V 722	3.3µF/1616/11V 935 124 42Y 733	Contact IPDIA Sales	4.7µF/2016/11V 935 124 42X 747		

<u>Parameters</u>	<u>Value</u>				
Capacitance range	390pF to 4.7μF ^(*)				
Capacitance tolerances	±15 % ^(*)				
Operating temperature range	-55 to 200 °C ^(**)				
Storage temperatures	- 70 to 215 °C				
Temperature coefficient	±1%, from -55 to +200°C				
Breakdown Voltage (BV)	30, 11V				
Capacitance variation versus RVDC	0.1 % /V (from 0 V to RVDC)				
Equivalent Serial Inductor (ESL)	Max 100 pH				
Equivalent Serial Resistor (ESR)	Max 0.1Ω				
Insulation resistance	50GΩ min @ RVDC,25°C 20GΩ min @ RVDC,200°C				
Aging	Negligible, < 0.001% / 10000h				
Reliability	FIT<0.017 parts / billions hours				
Capacitor height	Max 250µm ^(*)				

 $^(**) For extended temperature range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Silicon Capacitor product (EXSC). (**) For extended temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded X treme Temperature Range (up to +250 ^{\circ}C), see Embedded (up to +250 ^$





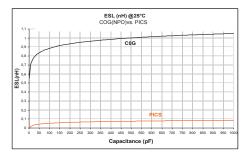
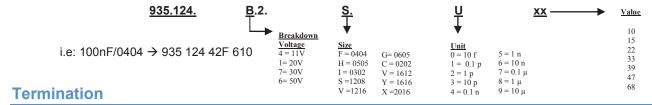


Fig.1 Capacitance change versus temperature variation compared to alternative technologies

Fig.2 Capacitance change versus voltage variation compared to alternative

Fig.3 ESL versus capacitance value compared to alternative technologies

Part Number



Pad finishing in Aluminum (3µm thickness +/-10%)

Applicable for almost all embedded applications.

Parts should be glued with non conductive paste. If conductive glue is used on the backside of the silicon cap, it is strongly recommended to connect the backside and pads 3&4 to the same level (GND preferred).

Pinning definition & Outline

pin#	Symbol	Description		
1, 2	Signal	Signal		
3. 4	GND	Ground		

Тур.		0202	0302	0303	0404	0505	0605	1208	1612	1616	2016
	Α	0.58 ±0.05	0.80 ±0.05	0.80 ±0.05	1.00 ±0.05	1.25 ±0.05	1.50 ±0.05	3.00 ±0.05	4.00 ±0.05	4.00 ±0.05	5.00 ±0.05
Comp. size	В	0.58 ±0.05	0.64 ±0.05	0.80 ±0.05	1.00 ±0.05	1.25 ±0.05	1.25 ±0.05	2.00 ±0.05	3.00 ±0.05	4.00 ±0.05	4.00 ±0.05
	С	0,15	0,15	0,15	0,15	0,15	0,15	0,15	0,15	0,15	0,15
	d	0,3	0,52	0,52	0,72	0,97	1,22	2,72	3,72	3,72	4,72
	е	0,3	0,36	0,52	0,72	0,97	1,22	1,72	2,72	3,72	3,72

Packaging

Tape and reel, tray, waffle pack or wafer delivery.

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^(*) Other values on request



IPD Capacitor Assembly Set Up

Rev 1.0 Application Note

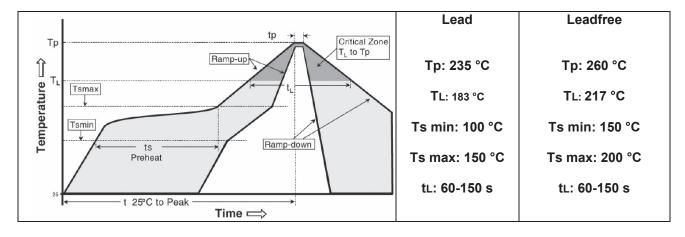
Outline

Silicon Capacitor for surface mounting device (SMD) assembly is a Wafer Level Chip Scale Packaging with the following features:

- Package dedicated to solve tombstoning effect of small SMD package;
- Package compatible with SMD assembly;
- Package without underfilling step;
- Interconnect available with various optional finishing for specific assembly.

Assembly consideration

- Standard pick & place equipment dedicated to WLCSP down to 400µm pitch.
- Solder paste type 3 in most cases of EIA size.
- Reflow has to be done with standard lead-free profile (for SAC alloys) or according to JEDEC recommendations J-STD 020D-01.



Process recommendation

After soldering, no solder paste should touch the side of the capacitor die as that might results in leakage currents due to remaining flux.

In order to use IPDiA standard capacitors within the JEDEC format and recommendation, the solder flux must be cleaned after reflow soldering step.

Notes: for a proper flux cleaning process, "rosin" flux type (R) or "water soluble" flux type (WS) is recommended for the solder printing material. "No clean" flux (NC) solder paste is not recommended.

In case the flux is not cleaned after the reflow soldering, the standard JEDEC would probably not be appropriate and the solder volume must be controlled:

- using smallest aperture design for the stencil, and using finer solder paste type 4 or 5 for a proper printing process.
- Mirroring pads would be the best recommendation



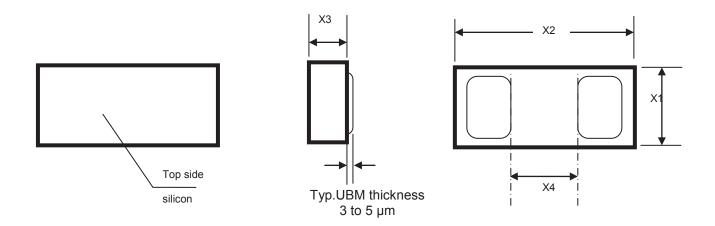


Pad recommendation

The capacitor is compatible with generic requirements for flip chip design (IPC7094). Standard IPDiA 3D package can be compliant with established EIA size (0201, 0402, 0603, ...).

Die size and land pattern dimensions is set up according to following range :

EIA size	0201	0402	0603	0805	1206	1812		
Dimension max(X1 x X2) mm	0.86x0.66	0.86x0.66 1.26x0.76 1.86x1.16 2.26x1.46		2.26x1.46	3.46x1.86	4.76x3.66		
Typical . die thickness X3 (mm)	0.1 or 0.4							
Typical pad size* (mm)	0.15x0.40	0.30x0.50	0.40x0.90	0.50x1.20	0.60x1.60	0.90x3.40		
Typical pad separation (X4 mm)	0.3	0.4	0.8	1	2	2.7		



After soldering, no solder paste should touch the side of the capacitor die as that might result in leakage currents due to remaining flux.

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Manual Handling Considerations

These capacitors are designed to be mounted with a standard SMT line, using solder printing step, pick and place machine and a final reflow soldering step. In case of manual handling and mounting conditions, please follow below recommendations:

- Minimize mechanical pressure on the capacitors (use of a vacuum nozzle is recommended).
- Use of organic tip instead of metal tip for the nozzle.
- Minimize temperature shocks (Substrate pre-heating is recommended).
- No wire bonding on 0402 47nF, 0402 100nF, 1206 1μF and 1812 3,3μF

Process steps:

- On substrate, form the solder meniscus on each land pattern targeting 100 μm height after reflow (screen printing, dispensing solder paste or by wire soldering).
- Pick the capacitor from the tape & reel or the Gel Pack keeping backside visible using a vacuum nozzle and organic tip.
- Temporary place the capacitor on land pattern assuming the solder paste (Flux) will stick and maintain the capacitor.
- Reflow the assembly module with a dedicated thermal profile (see reflow recommendation profile).



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